

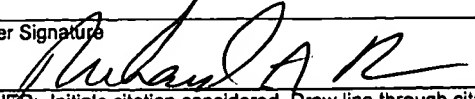
Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 12732-068001	Application No.
Information Disclosure Statement by Applicant (Use several sheets if necessary) (37 CFR §1.98(b))		Applicant Hideto Ohnuma et al.	
		Filing Date August 10, 2001	Group Art Unit

1-5978 U.S. PTO
 09/925512
 08/10/01

U.S. Patent Documents							
Examiner Initial	Desig. ID	Patent Number	Issue Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner Initial	Desig. ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation	
							Yes	No
	AL							
	AM							
	AN							
	AO							
	AP							

Other Documents (include Author, Title, Date, and Place of Publication)		
Examiner Initial	Desig. ID	Document
RB	AQ	C.W. Kim et al.; "42.1: A Novel Four-Mask-Count Process Architecture for TFT-LCDs"; <u>SID 00 Digest</u> ; pp. 1006-1009; 2000
	AR	
	AS	
	AT	

Examiner Signature 	Date Considered 2/9/04
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	

Substitute Form PTO-1449 (Modified)	U.S. Department of Commerce Patent and Trademark Office	Attorney's Docket No. 12732-068001	Application No. 09/925,512
Information Disclosure Statement by Applicant (Use several sheets if necessary) (37 CFR §1.98(b))		Applicant Hideto Ohnuma et al.	
		Filing Date August 10, 2001	Group Art Unit 2812

U.S. Patent Documents							
Examiner Initial	Design ID	Patent Number	Issue Date	Patentee	Class	Subclass	Filing Date If Appropriate
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

Foreign Patent Documents or Published Foreign Patent Applications								
Examiner Initial	Design ID	Document Number	Publication Date	Country or Patent Office	Class	Subclass	Translation	
							Yes	No
RFB	AL	EP 1 003 223	05/24/2000	Europe	H01L	29/786	N/A	
	AM	2001-94113	04/06/2001	Japan	H01L	29/786	XX	
	AN							
	AO							
	AP							

Other Documents (include Author, Title, Date, and Place of Publication)		
Examiner Initial	Design ID	Document
	AQ	
	AR	
	AS	
	AT	

Examiner Signature <i>Richard A. Booth</i>	Date Considered 2/9/04
EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	